

# **Ultrafast and Close-Space Processing Methodologies for Scalable Perovskite Thin-Film Growth**

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## **Project Background and Motivation**

Metal-halide perovskites have demonstrated exceptional optoelectronic properties and rapid performance gains across photovoltaics, photodetectors, and light-emitting devices. However, a major bottleneck for industrial translation remains the scalability, reproducibility, and throughput of perovskite thin-film growth.

Most laboratory-scale demonstrations rely on slow, solution-based processing routes that are sensitive to ambient conditions and difficult to control over large areas. In contrast, ultrafast and close-space deposition techniques—such as close-space sublimation (CSS), flash evaporation, and high-rate thermal evaporation—offer compelling advantages, including:

- Deposition times reduced from minutes to seconds
- Excellent thickness and stoichiometry control
- Compatibility with large-area and roll-to-roll manufacturing
- Reduced solvent-related variability
- Direct integration with vacuum-processed device stacks

Recent advances have shown that perovskite films grown under extreme growth rates and short source-substrate distances can achieve high crystallinity, low defect density, and excellent device performance, challenging the traditional paradigm that slow crystallization is required for high-quality perovskite films.

This project aims to systematically investigate ultrafast and close-space processing methodologies for perovskite thin-film growth, with a focus on understanding growth kinetics, structure-property relationships, and process-performance trade-offs.

## **Objectives**

The main objectives of this Master's thesis are:

1. To understand the physical principles governing ultrafast and close-space thin-film growth.
2. To develop perovskite thin films using close-space and high-rate vacuum deposition techniques.
3. To study how growth parameters affect crystallization dynamics, microstructure, and optoelectronic properties.

4. To benchmark ultrafast-grown perovskite films against conventionally processed films.
5. To identify scalable process windows suitable for industrial translation.